## THEORY AND APPLICATION OF PHOTOELECTRON SPECTROSCOPY

# XVI\*. PHOTOELECTRON SPECTROSCOPY AND MOLECULAR **CONFOR-**MATIONS: Ge-C AND Sn-C HYPERCONJUGATION AND THE CONFOR-MATION OF ALLYLGERMANES AND -STANNANES

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#### **SUMMARY**

The photoelectron spectra of vinyl- and allylgermanes and -stannanes have been investigated. The conformations of allylgermanes and allylstannanes are shown to be determined by Ge–C and Sn–C hyperconjugation. The hyperconjugative ability of the C-M(M=Si, C, Ge and Sn) bonding MO's with the ethylene  $\pi$ -MO is explained by simple perturbation theory. This result represents a new and independent confirmation of the hyperconjugative interaction mechanism.

## **INTRODUCTION**

In preceding publications<sup> $1-4$ </sup> we developed a new application of photoelectron (PE) spectroscopy to study molecular conformations. We showed that allyltrimethylsilane  $(VI)$  exists in conformation  $(A)$ , due to a strong hyperconjugative interaction between the CH<sub>2</sub>-Si bonding MO and the adjacent ethylene  $\pi$  system<sup>1</sup>. Using the PE spectra of tetraethylgermane (VII), triethylvinylgermane (VIII), triethylallylgermane (Ix), tetra-n-butylstannane (X), tri-n-butylvinylstannane (XI) and tri-n-butylallylstannane (XII) we have extended our investigations<sup> $1-4$ </sup> to Ge–C<sup>5,6</sup> and Sn–C<sup>5,7</sup> hyperconjugation ( $\sigma$ – $\pi$  interaction) with ethylene. We obtain the first evidence in the case of  $(IX)$  and  $(XII)$  for the conformations  $(B)$  and  $(C)$ , and account for the differences in the strengths of  $Si-C^{1,4,5,8}$ ,  $C-C^{4,9}$ ,  $Ge-C$  and Sn-C hyperconjugations with ethylene.

## **RESULTS AND DISCUSSION**

Fig 1 shows the PE spectra of (VII) to (XII), and Fig 2 the correlation dia-

l **For Part XV see ref. 16.** 



germane (IX), tetra-n-butylstannane (X). tri-n-butylvinylstannane (XI), and tri-n-butylallylstannane (XII).

Fig. 2. Correlation diagrams of the highest occupied MO's in tetraethylgermane (VII), triethylvinylgermane (VIII) and triethylallylgermane (IX) and in tetra-n-butyl-stannane (X), tri-n-butylvinylstannane (XI), and tri-n-butylallylstannane (XII). The numbers printed above the levels are vertical ionization potentials [eV]\_ The shaded areas correspond to not well resolved ionization ranges in the spectra shown in Fig 1. Intensity measurements, as well as analogy with the silicon compounds  $(V)$  and  $(VI)^{1.4}$ , suggest that two Ge-C ionizations occur in this range.

grams of the highest occupied molecular orbitals (MO's) of these compounds. The midpoint of the Ge-C ionisation in (VII) is observed at 9.3 eV, the  $\pi$  ionization in ethylene is found at 10.51  $eV^{10}$ . The  $\pi$ -MO (10.3 eV) and the antibonding Ge-C  $\pi$  combination (9.2 eV) (cf. representation of this combination) do not significantly **change in (VIII).** 

CMe <sub>a</sub>	$CH2=CH-CMe3$	$CH2=CH-CH2-CMe3$
	(II)	(III)
SiMe <sub>4</sub>	$CH2=CH-SiMe3$	$CH2=CH-CH2-SiMe3$
$(\mathbf{IV})$	W)	(VI)

<sup>\*</sup> The He-I (584 Å) photoelectron spectra were measured on a PS-16 photoelectron spectrometer from Perkin-Elmer, Beaconsfield, England.

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In  $(IX)$  the  $\pi$ -MO (10.7 eV) is stabilized (thus its ionization can be seen in the FE spectrum as the well resolved band 4), and one MO in the Ge-C ionization range (8\_8 eV) is destabilized by 0.4 eV (thus the corresponding PE band can be **clearly**  recognized as the shoulder 1). We obtain similar results in the case of the tin compounds (X) to (XII). Due to the already high lying Sn–C MO's [8.7 eV in  $(X)$ ] in (XI), the  $\pi$ -MO (10.0 eV) can be observed as the separate band (4). For the same reason this band moves almost wholly under the  $\sigma$  ionization range (shoulder 4) in  $(XII).$ 



The above analysis shows one Ge–C and Sn–C MO in  $(IX)$  and  $(XII)$  to be raised as compared to those in (VIII) and (XI), and the  $\pi$ -MO to be lowered in both cases. The results are onty consistent with conformations (B) and (C), for which; contrary to  $(D)$  and  $(E)$ , the observed splitting would be expected, because of hyperconjugation between the Ge-C and Sn-C bonding MO's and the  $\pi$ -MO. In full agreement with this interpretation are recent ESR-spectroscopic results for  $\beta$ germylalkyl- and  $\beta$ -stannylalkyl radicals<sup>11,12</sup> which show that these radicals also prefer conformations (F) and (G) in which hyperconjugation is possible.



The interaction between two MO's  $\int$ in our case between the ethylene  $\pi$ -MO and the C-M( $M = Si$ , C, Ge and Sn)] MO's is inversely proportional to their energy difference. Comparing columns 3 (energy difference between the interacting MO's) and  $6$  (HOMO, highest occupied MO, destabilization by hyperconjugation) of TABLE-1



<sup>*a*</sup> Vertical ionization potentials. <sup>*b*</sup> Energy differences between the  $\pi$ -MO in ethylene (10.5 eV<sup>10</sup>) and the C-M bonding MOs. "HOMO destabilizations of the allyl compounds. "Ref. 13. "Ref. 4. "Ref. 14. "Ref. 15.

Table 1, we note that the effects of the substituents  $CH_2-SiMe_3$ ,  $CH_2-CMe_3$ ,  $CH_2$ -GeEt<sub>3</sub>, and CH<sub>2</sub>-SnBu<sub>3</sub> on the  $\pi$  system of ethylene follow this rule. This result independently confirms the postulated hyperconjugative interaction mechanism.

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